



Charge-transfer engineering strategies for tailored ionic conductivity at oxide interfaces

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Exploiting the electronic charge-transfer across oxide interfaces has emerged as a versatile tool to tailor the electronic and magnetic properties of oxides. Such charge-transfer concepts have been applied to drive insulating oxides into metallic states, to trigger magnetism in non-magnetic oxides, and to render gate-tunable low-dimensional superconductors. While the richness in the electronic and magnetic properties of these systems is the main focus of research, the implications for the ionic transport at oxide interfaces have not received much attention so far. In this communication, we propose that charge-transfer strategies can also be applied to boost ionic charge carrier concentrations at interfaces by orders of magnitude. Based on numerical space-charge modeling, we will illustrate how the 'p-type' charge-transfer predicted between SrO-terminated SrTiO₃ and LaAlO₃ may foster 2-dimensional oxygen ion conduction at the interface. The ion conduction is effectively separated from impurity dopants, which may allow large concentrations of oxygen vacancies to be achieved in the absence of trapping phenomena. The interface promises high ionic conductivity with nanoscale confinement, potentially allowing the design of field-tunable ionic devices.

The rich physical and chemical properties of complex oxides have sparked new fields of research based on electronic and ionic charge transport.^{1–4} Various sustainable electronics and energy concepts employ novel oxide devices that exhibit tailored electronic properties (electronics), tailored ionic properties (ionics), or both (ionotronics) by combining appropriate oxides with nanoscale precision.^{3,5–7}

Controlling ions in these systems in a similar way to how we control electrons reflects an overarching goal within the field: controlled ionic conduction and atomically defined ionic defect structures enable the realization of electrochemical devices such as batteries, fuel cells, electrolyzers, gas separation membranes, memristive memory devices, sensors, or tailored field-effect and spintronic devices.^{4,8–15} A major challenge in the

field is the precise control of the sluggish motion of 'large' and 'slow' ions, which typically limits charging times in batteries, operation temperatures of fuel cells, and switching performance of memristive memory devices. Novel concepts aiming to enhance, accelerate, and control ionic motion in solids are therefore highly desired.

To date, typical control strategies for oxygen ion conductivity are based on the chemical doping of ion-conducting oxides, *i.e.* the admixture of lower-valence cations, which proportionally increases the concentration of oxygen vacancies in most oxides.^{6,16,17} At high concentration, however, the interaction between dopants and associated vacancy defects, or in between the vacancy defects themselves suppresses ion conduction.^{18–20} Therefore, it is highly desirable to spatially separate dopants and vacancy defects by a heterogeneous doping approach²¹ or by exploiting space charge layers at grain boundaries.²² Epitaxy of oxides has moreover been used to stabilize ion conducting crystallographic phases^{17,23} and to harvest strain effects to modulate and lower the energy barriers for ion migration.^{24–26}

Atomically-defined oxide interfaces have evolved as a huge playground for generating novel electronic phenomena based on the interaction between the charge, spin, orbital, and lattice degrees of freedom of the materials at their atomic interfaces.^{1,2} A major concept applied in the field is the concept of electronic charge-transfer which employs the transfer of electrons (or holes) between neighboring materials, in order to tailor the electronic transport along their interface (Fig. 1a). Charge-transfer here refers to the static exchange of charge across the interface driven by the alignment of the Fermi level of the two neighboring materials. This charge-transfer process then allows tailoring of the electronic transport along the interface through a confined modulation of the charge carrier concentrations.

Ionic materials, such as oxides and their interfaces, often-times need to be considered as mixed ionic–electronic systems,^{27–33} *i.e.* electronic charges as well as ions participate in the charge-transfer process across the interface (Fig. 1b). The resulting ionic structure often dictates the observed electronic or magnetic behavior.^{34–37}

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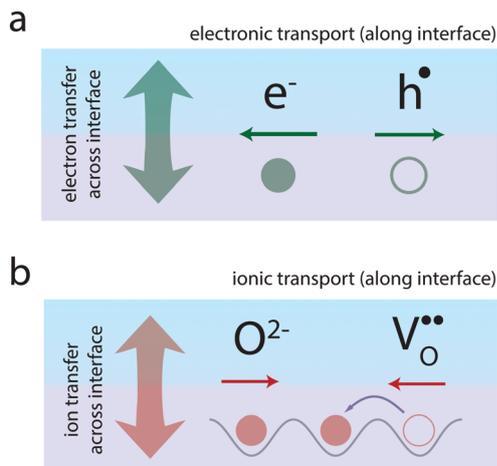


Fig. 1 Schematic illustration of (a) electronic and (b) ionic charge-transfer and transport at oxide interfaces. Charge-transfer denotes the static exchange of charge across the interface of two neighboring materials (arrows perpendicular to the interface). As a result of the process, the transport of electronic (a) and ionic (b) charge carriers along the interface is modulated.

Beyond electronic phenomena, ionic charge-transfer also yields new opportunities to tailor and functionalize the ionic properties of oxide interfaces: by forcing charge-transfer to take place primarily *via* exchange of ions from one side of the interface to the other, one may tailor the ionic conductivity along the interface (Fig. 1b). Here, ion-transfer refers to ions (or ionic defects) crossing the interface in order to align their electrochemical potential, resulting in a static ionic space charge layer evolving at the interface. Ion conduction, respectively,

refers to the migration of the ions along the interface under an applied electric field. In analogy to electrons and holes, such ionic transport can often be understood in terms of the migration of vacancies of the respective ion. This is particularly the case in oxides, where oxygen ion conduction typically takes place *via* oxygen vacancy migration in the opposite direction (Fig. 1b). Therefore, if one could use charge-transfer processes to accumulate oxygen vacancies at an interface, one may dramatically enhance the oxygen ion conductivity along the interface.

Similar to the electronic conductivity, ionic conductivity allows two inherent tuning parameters: the total concentration of ionic species that contribute to ion transport and the mobility of individual ions. Charge-transfer phenomena particularly allow tuning of the concentration of ions (and ionic defects) at oxide interfaces. Lattice relaxation and interface-induced strain can lower the energy barriers for ion migration.^{24–26}

In this communication, we discuss the potential of using p-type charge-transfer at atomically tailored oxide interfaces for enhanced oxygen ion conductivity. As we argue, an accumulation layer of oxygen vacancy defects forms at such interfaces as a result of the alignment of the chemical potential for oxygen vacancies across the interface. Here, we particularly address the atomically defined interface of the two complex oxides LaAlO₃ and SrTiO₃, serving as a model system for charge-transfer oxide interfaces.^{38–40}

LaAlO₃/SrTiO₃ interfaces can be achieved in two distinct terminations, denoted as n-type and p-type interfaces (Fig. 2), whereas the charge-transfer process is driven by the polar nature of LaAlO₃.^{39,40} The n-type LaAlO₃/SrTiO₃ interface, characterized by a TiO₂-termination of SrTiO₃, and thus an atomic stacking of (TiO₂)/(LaO)⁺ at the interface, reflects a major

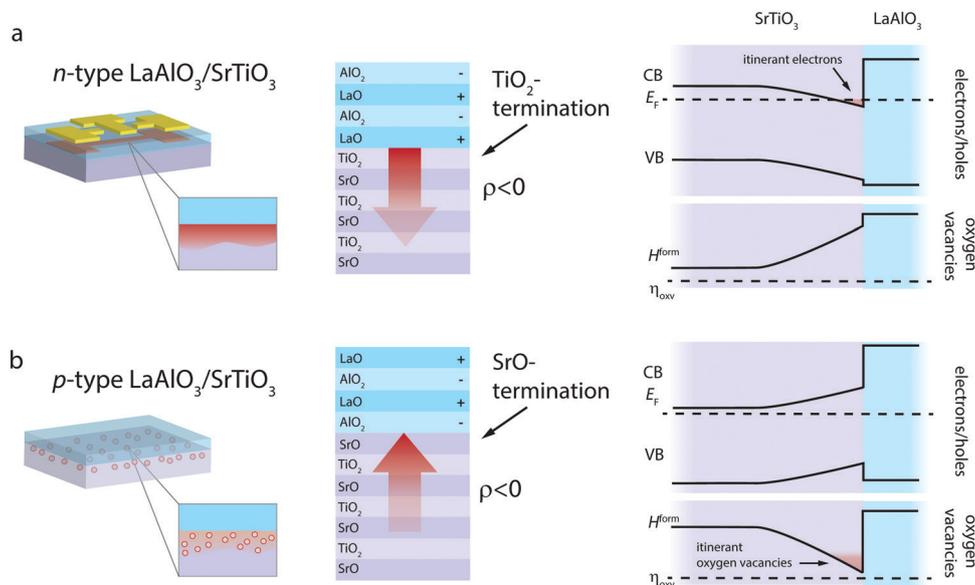


Fig. 2 n-Type and p-type LaAlO₃/SrTiO₃ interfaces as determined by the chemical termination at the interface: the n-type interface (a) is characterized by a TiO₂-termination of SrTiO₃, while the p-type interface (b) is characterized by a SrO-termination of SrTiO₃, resulting in charge-transfer and thus an electrical field with opposite signs (red arrow). As a result, one obtains electronic band bending as well as a bending of the effective enthalpy of formation for oxygen vacancies ($H_{\text{ox}}^{\text{form}}(x) = H_0^{\text{form}} + 2e\phi(x)$) at the interfaces. As a result, one expects itinerant electrons to accumulate at the n-type interface (red area) and itinerant oxygen vacancies (at elevated temperature) at the p-type interface.



success story of electronic charge-transfer engineering in complex oxides. Since its discovery in 2004,³⁹ it has been the prime example to demonstrate controlled metal-to-insulator transitions,^{14,41} gate-tunable superconductivity,⁴² coexisting ferromagnetism and superconductivity,⁴³ and enhanced electron mobility^{14,44,45} arising at an oxide interface. These phenomena are based on the net transfer of negative charge (*i.e.* electrons and/or negatively charged ionic defects) from LaAlO₃ into SrTiO₃ (Fig. 2a).

In contrast, the p-type interface, characterized by a SrO-termination of SrTiO₃ and thus an atomic stacking of (SrO₂)/(AlO₂)⁻ at the interface, promises to cause the transfer of positive net charge across the interface, *i.e.* the transfer of holes and/or positively charged ionic defects from LaAlO₃ into SrTiO₃ (Fig. 2b). In this case, the electric field established at the interface in response to the charge-transfer has the opposite sign as compared to the n-type case (red arrows in Fig. 2).

Experimentally, the p-type LaAlO₃/SrTiO₃ interface was found to be electronically insulating^{39,40,46} and only a few studies report on significant hole formation at the interface.⁴⁷ The observed insulating behavior of p-type interfaces is typically explained by the formation of oxygen vacancies on the SrTiO₃ side of the

interface, *i.e.* an ionic compensation of charge-transfer at the interface. This process is detrimental to the potential use of the p-type LaAlO₃/SrTiO₃ interface in electronic applications. For ionic applications, however, this process is desired and bears the opportunity for oxygen ion conductivity along the interface. As we suggest below, this ionic charge-transfer boosts the ionic charge carrier concentration at the interface by three to four orders of magnitude as compared to the bulk. Moreover, effective spatial separation of ionic charge carriers and potential trapping defects can be achieved, yielding a promising starting point also for enhanced mobility of the vacancies. To demonstrate this, we conducted thermodynamic space-charge calculations that allow evaluation of both electronic and ionic contributions to the charge-transfer at the interface.³⁸

In Fig. 3, we consider the p-type LaAlO₃/SrTiO₃ interface exposed to elevated temperature ($T = 950$ K). At this temperature, oxygen ions have sufficient mobility to participate in the charge-transfer process.⁴⁸ In order to model the ionic properties of the interface, we assume that the atomically defined termination at the interface forces a charge-transfer of order of $\sigma_q \approx +1 \times 10^{14} \text{ e cm}^{-2}$,³⁸⁻⁴⁰ which defines the electric field at the interface *via* the Gauss law. We then self-consistently

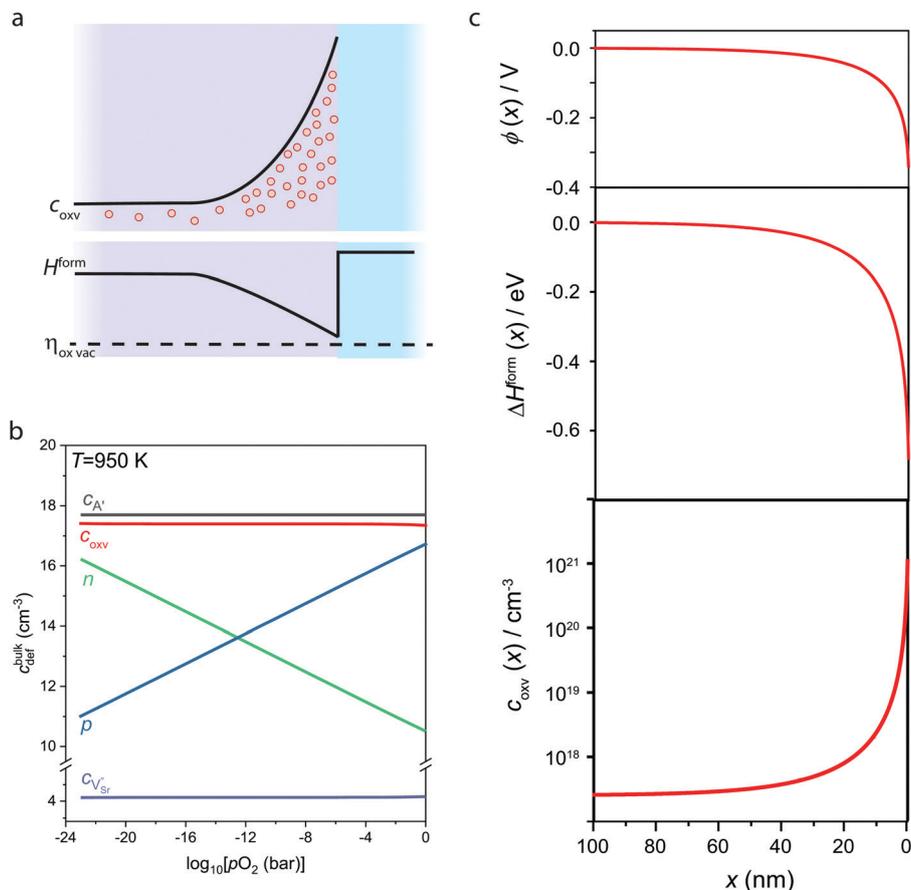


Fig. 3 Ionic–electronic space charge calculations for p-type LaAlO₃/SrTiO₃. (a) Schematic of the resulting oxygen vacancy accumulation layer. (b) Bulk defect concentrations as a function of ambient oxygen pressure (p_{O_2}). (c) Space charge potential, $\phi(x)$, effective formation enthalpy for oxygen vacancies, $\Delta H^{\text{form}}(x) = H^{\text{form}}(x) - H_0^{\text{form}}$, and the resulting concentration profile of oxygen vacancies, c_{oxv} , assuming a positive net charge-transfer of $\sigma_q \approx +1 \times 10^{14} \text{ e cm}^{-2}$. Here, the space charge potential was solved for an oxygen pressure of $p_{\text{O}_2} = 1$ bar at $T = 950$ K.



calculate the space-potential $\phi(x)$ at the interface (Fig. 3c) by solving Poisson's equation

$$\epsilon_r \epsilon_0 \frac{d^2 \phi(x)}{dx^2} = \rho(x) = e[-n(x) + p(x) - c_{A'} + 2c_{\text{oxv}}(x)], \quad (1)$$

where x denotes the distance from the interface. The local charge density $\rho(x)$ includes electronic and ionic contributions, *i.e.* the local electron and hole concentrations, $n(x)$ and $p(x)$, as well as the impurity concentration, $c_{A'}$, and the local oxygen vacancy concentration, $c_{\text{oxv}}(x)$. (For more details on the numerical modeling, the reader is referred to ref. 29, 32 and 38.)

The bulk concentrations of electronic and ionic defects serve as boundary conditions, and are obtained from standard defect chemical treatment of SrTiO₃ with a typical background impurity concentration of $c_{A'} = 5 \times 10^{17} \text{ cm}^{-2}$, which yields bulk concentrations of electrons, holes, and oxygen vacancies in different oxygen environments (Fig. 3b).^{29,48–50} Notably, the oxygen vacancy concentration in the bulk SrTiO₃ is almost constant and within the ppm level over a wide range of oxygen pressures, as under these conditions oxygen vacancies primarily compensate impurity dopants which are unavoidably incorporated during thin film or single crystal synthesis. As ionic applications typically need to operate in oxygen or oxygen-rich atmospheres the high oxygen pressure regime ($10^{-8} \lesssim p\text{O}_2/\text{bar} \lesssim 1$) is most relevant for our discussion.

Similar to electronic band bending, the non-zero space charge potential (Fig. 3c, top) resulting from the charge-transfer affects also the local concentration of mobile ionic defect species and in particular oxygen vacancies. In analogy to adapting a common Fermi energy across the interface, also the electrochemical potential for oxygen vacancies, η_{oxv} , (and all other ionic species) strives for equilibration

$$\eta_{\text{oxv}} = H_0^{\text{form}} + 2e\phi(x) + k_B T \ln c_{\text{oxv}}(x) = \text{const.}, \quad (2)$$

with H_0^{form} being the standard formation enthalpy for oxygen vacancies. A non-zero space charge potential hence directly affects the local defect concentration $c_{\text{oxv}}(x)$ in a similar way as it affects the local concentration of electrons or holes (electronic band bending). In terms of defect formation, eqn (2) can be considered as an effective formation enthalpy for oxygen vacancies

$$H^{\text{form}}(x) = H_0^{\text{form}} + 2e\phi(x) \quad (3)$$

that varies toward the interface (*cf.* Fig. 2). In this way, the electrical potential affects the local formation and distribution of oxygen vacancies.

At negative potential, such as resulting in the case of the p-type LaAlO₃/SrTiO₃ interface (Fig. 3c, top), this particularly results in a reduced effective enthalpy of formation close to the interface (center) and hence accumulation of oxygen vacancies toward the interface (bottom). It is evident that the concentration of oxygen vacancies reaches up to 10^{21} cm^{-3} , which is about four orders of magnitude higher than the bulk concentration ($2.5 \times 10^{17} \text{ cm}^{-3}$). The accumulation layer of oxygen vacancies at the interface corresponds to a local enhancement of ionic charge carriers which at elevated temperature facilitates ionic charge transport along the interface. Note that

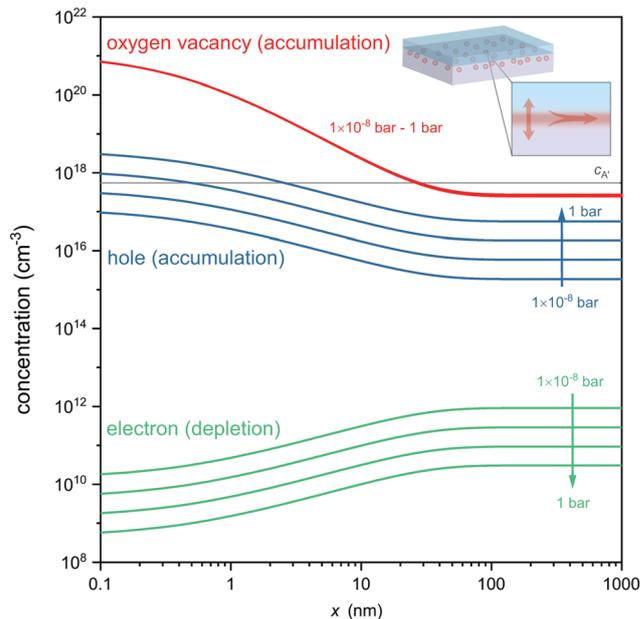


Fig. 4 Defect concentration profiles at the p-type LaAlO₃/SrTiO₃ interface calculated for different oxygen pressures. The accumulation layer of oxygen vacancies (red lines) is robust against a variation of $p\text{O}_2$, and exceeds the hole concentration (blue) as well as the impurity concentration (gray line) by orders of magnitude.

elevated temperatures are required as ionic charge carrier transport along the interface will take place *via* drift-diffusion. Therefore, the ionic conduction along the interface is expected to be a thermally activated process, which is fundamentally different from the behavior of electron gas reported for the n-type LAO/STO interface. Enhanced oxygen ion conduction is nevertheless inferred from the accumulation of oxygen vacancies toward the interface, as the diffusion coefficient (related to ion mobility *via* Einstein-relation) scales directly with the vacancy concentration.⁴⁸

Fig. 4 displays the concentration profiles expected for oxygen vacancies, electrons and holes at different oxygen atmospheres. Note that logarithmic scales were used in Fig. 4 to allow comparison of the concentration profiles of oxygen vacancies, electrons and electron holes, which differ by orders of magnitude in different $p\text{O}_2$ environments. Under each of these conditions an accumulation layer of oxygen vacancies is established, indicating the robustness of the formed ionic space charge layer against a variation in an ambient oxygen atmosphere. This also highlights that the expected oxygen vacancies cannot be removed by oxidation of the entire heterostructure, as their origin is not a classical reduction, but the charge-transfer process and band alignment at the atomically engineered interface. Unlike classical reduction, these oxygen vacancies are highly confined to about 10 nm from the interface and exist in the absence of compensating electrons (which are even depleted from the interface in response to the electric field, *cf.* Fig. 4). Moreover, the ionic charge-transfer is favored as compared to hole-transfer under these conditions ($c_{\text{oxv}}/p \approx 10^3$), yielding a high transfer number for ionic conductivity along the interface. Based on the assessment of the carrier concentrations,



the interface conductivity should hence be governed to a wide extent by oxygen ion conduction, while electron and electron hole contributions are orders of magnitude smaller. Finally, the high ionic charge carrier concentration is achieved in the absence of significant extrinsic doping of the interface (gray line in Fig. 4) so that trapping of oxygen vacancies is avoided ($c_{\text{oxv}}/c_{A'} \approx 10^3$).

In summary, some of the main future promises of the p-type LaAlO₃/SrTiO₃ heterointerface are

- (1) High thermal stability.
- (2) High ionic transfer number.
- (3) Absence of trapping effects at large carrier concentration.
- (4) Strong confinement of enhanced oxygen ion conductivity.

Conclusions

Our model calculations show how charge-transfer phenomena in oxide heterostructures may be used to tailor ionic conductivity at oxide interfaces. Yet, experimental verification of enhanced interface ion conduction at this particular interface is challenging, as potential interface contributions need to be separated from substrate contributions,^{24,27,32} posing additional challenges to thin film synthesis, sample design, and the characterization of such nanoscaled ionic systems. Electrical characterization of the ionic contributions of transport along the interface may moreover require the use of electron-blocking electrodes to isolate ionic conductivity from electronic conductivity. In fact, the electron hole contribution stemming from the bulk of STO may otherwise mask the ion conduction contribution of the interface.^{24,51,52} Characteristic pO_2 -dependencies of transport properties can help to identify residual electronic contributions ($\propto pO_2^{\pm 1/4}$) and to separate unambiguously ionic contributions (which are expected to be independent of an oxygen atmosphere, see Fig. 4). In any case, careful reference measurements on the involved bulk materials are required as (ion and electronic) bulk contribution stemming from STO single crystals has oftentimes be suspected to be misinterpreted as thin film or interface contributions.^{24,51,52} Moreover, a careful evaluation of temperature dependence can provide further insights in this case, as electronic contributions such as the p-type carrier concentrations in the bulk of STO have well-known and characteristic activation energies,⁵⁰ which typically differ from the activation of ion migration which typically results in a significantly steeper temperature dependence. Furthermore, the charge-transfer relies on the atomic configuration at the interfaces, making atomically defined oxide epitaxy indispensable for achieving an enhancement of ionic conductivity. One should also note that SrTiO₃ reflects a well-established model system for mixed ionic–electronic conduction in oxides, but it is not the most promising ion conductor by itself. Therefore, for use in classical ionic applications such as ion conducting electrolytes, one may envision achievement of a similar charge-transfer process at an interface to zirconia or ceria, which should be accessible if the interface termination can be controlled in the desired way.

The nanoscale control of ions in the solid may ultimately result in realizing highly tailored and controllable ion-conducting

channels in nanoscaled all oxide devices. The inherent confinement of this ion channel may pave a way for novel field-tunable ionic devices, as electric field-effects superimposed to the inherent space charge layer may allow tuning of the ionic carrier concentration as well as their spatial distribution. In this way, one may compose an ionic device that acts like an ion valve operating at elevated temperature and selectively allowing for ion migration along the interface.

There is no fundamental restriction to use similar design principles to enhance also ionic conduction in Li-ion conductors or proton conductors, when atomically defined interfaces to a polar material (such as LaAlO₃) can be achieved. Our concept hence emphasizes the chances and opportunities of designing interfaces with tailored ionic charge-transfer properties for ionic devices in oxides and beyond. Therefore, adopting band engineering strategies applied in electronics for tunable ionic interface properties is a promising future perspective for achieving novel devices and scientific insights. While our thermodynamic modelling results illustrate the potential of charge-transfer phenomena to engineer ionic properties, a joint experimental effort across the research community will be required to realize tailored ion conducting interfaces based on charge-transfer in ionic devices.

Conflicts of interest

There are no conflicts of interest to declare.

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